A		Reg. No. :								
		Question 1	Paper	: Cod	e: 59	501]			
	B.E.	/ B.Tech. DEGREE H	EXAM	INATI	ON, I	NOV 2	2019			
		El	ective							
		Electronics and Instr	ument	ation E	ngine	ering				
		15UEI901-VLS	I SYST	LEW D	ESIG	N				
		(Regul	ation 2	2015)						
Dura	ation: Three hours			М	aximu	m: 10	0 Mai	rks		
		Answer A	LL Qu	estions						
		PART A - (10) x 1 =	10 Ma	rks)					
1.	Which technology has photo-electronic properties?							CO1		
	(a) GaAs	(b) BiCMOs	(c)) CMO	S			(d) n	MOS	5
2.	Approximately how in MSI	w many numbers of tra	ansisto	ors per	chip i	s avail	able			COI
	(a) 10-100	(b) 100-1,000	(c)) 1,000-	-10,00	00		(d) >	· 10,0	000
3.	In the design rules the implant layer has CO2-									
	(a) $2\lambda \ge 2\lambda$	(b) $4\lambda x 4\lambda$	(c)) 6λ x 6	λ			(d) 8λ x 8λ		
4.	The ratio of pull-up to pull-down for an inverter directly driven by an CO2 inverter is									
	(a) 2/1	(b) 3/2	(c)) 8/1				(d) 4	/1	
5.	Precharge low circuits are slower to pull up than precharge high CO3									
	circuits are to pull down. This statement is									
	(a) True	(b) False	(c)) based	on lo	gic		(d) b	ased	on clo
6.	Barrel shifter requires control lines.									CO3
	(a) 2N	(b) N^2	(c)	$2N^{2}$				(d) N	1	
7.	The line connecting OR Plane and AND Plane in an NMOS PLA is CO4 called									
	(a) Product line (b) Sum line (c) Connector (d)) Inte	rconi	nection		

8.	PLA	A contains				CO4-R						
	(a) AND and OR arrays			(b) NAND and OR arrays								
	(c) l	NOT and AND arr	ays	(d) NOR and OR arrays								
9.	insi	is used for the design of the		CO5-R								
	(a) S	Signal	(b) Variable	(c) Constant	(d) Entity							
10.	The	full form of VHD	L is			CO5-R						
	a)Very High Descriptive Language											
	(b)Very High Definition Language											
	(c)Variable Definition Language											
	(d) None of the Mentioned											
PART - B (5 x 2 = 10 Marks)												
11.	Def	ine body effect.		CO1-U								
12.	Mer	ntion techniques to		CO2-U								
13.	Def	ine Contamination		CO3-U								
14.	List	the steps used for		CO4-U								
15.	Wha	at is subprogram?		CO5-R								
	$PART - C (5 \times 16 = 80 Marks)$											
16.	(a) Discuss in detail about the modes of operation of MOS transistor with necessary equations.					(16)						
	Or											
	(b)	(i) Derive the NM	CO1- U	(8)								
		(ii) Describe the	Enhancement mode op	eration of MOS transistor.	CO1- U	(8)						
17.	(a)	Determine the public by another nMOS	A A	o of nMOS Inverter driven	CO2 -U	(16)						
			Or									
	(b)	• •	ll up to pull-down ratio er through pass transist	o of nMOS Inverter driven or is 8:1.	CO2 -App	(8)						
		(ii) Draw the st Inverter and CM	0	k diagram of the nMOS	CO2- App	(8)						

18. (a) (i)Design an 4 x 4 Barrel Shifter and explain its operation.CO3- App(16)(ii)Design a 3 input Tally Circuit.CO3-App

Or

- (b) (i)Design a 4 x 1 Multiplexer using CMOS static pull up device. CO3- App (16)
 (ii) Sketch a clocked precharged high, 2 input NMOS NOR CO3-App Gate
- 19. (a) What is programmable logic devices? Explain the different types CO4- App (16) of PLD in detail

Or

(b) Design and sketch the stick diagram of a NMOS NAND-NAND CO4- App (16) PLA realization of the product lines with three output lines.

$$P_0 = \overline{I_0 I_1} \qquad P_1 = \overline{I_0 I_1} \qquad P_2 = I_0 I_1 \overline{I_2} \qquad P_3 = I_0 I_2$$
$$Y_0 = P_1 \qquad Y_1 = P_0 + P_2 + P_3 \qquad Y_2 = P_1 + P_2$$

20. (a) Explain in detail about the design procedure of RTL. CO5- U (16) Or

(b) (i)Write a testbench VHDL program for NAND gate. CO5 - App (8)
(ii)Draw the diagram of down counter and write the VHDL CO5- App (8) program.

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